

10/594480  
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New PCT National Phase Application  
Docket No. 2691-000052/US

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant(s): Yoshiharu OHTA et al.  
Int'l App. No.: PCT/JP2005/005768  
Application No.: **NEW APPLICATION**  
Filed: September 28, 2006  
For: **SEMICONDUCTOR POLISHING COMPOSITION**  
(as amended)

**PRELIMINARY AMENDMENT**

Customer Service Window September 28, 2006  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314  
**Mail Stop PCT**

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application. Prior to examination of the present application, please consider the following:

**Amendments to the Title** begin on page 2 of this Preliminary Amendment.

**Amendments to the Abstract** begin on page 3 of this Preliminary Amendment.

**Amendments to the Specification** begin on page 4 of this Preliminary Amendment.

**Amendments to the Claims** begin on page 5 of this Preliminary Amendment.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
<b>Total</b>	16	-	20	=	0
<b>Independent</b>	1	-	3	=	0

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**IN THE TITLE**

Please ensure the title reads as follows:

**"SEMICONDUCTOR POLISHING COMPOSITION"**